

A Low-Power MOS-Only Potentiostatic $\Delta\Sigma$ ADC Architecture for Electrochemical Sensors

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- 1 Introduction
- 2 Electrochemical $\Delta\Sigma$ Architecture
- 3 Low-Power MOS-Only Circuits
- 4 Low-Cost Monolithic Smart Sensor
- 5 Experimental Results
- 6 Conclusions

Motivation and Proposal

► **Integrated chemical** sensors

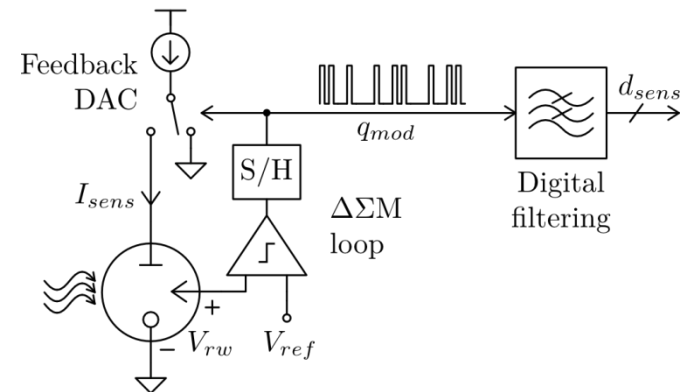
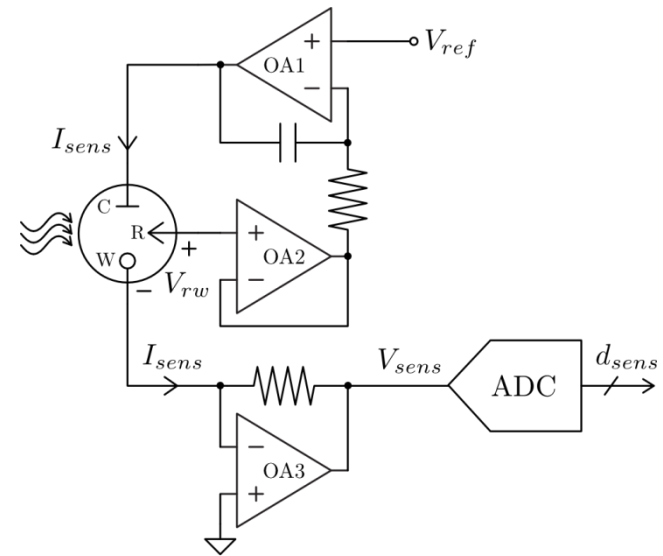
- Interaction with microorganisms
- Selectivity by functionalization
- Speed limitation
- Reduced life time
- Packaging costs

► **Electrochemical** family

- CMOS compatible
- **Potentiostatic** biasing
- **Amperometric** read-out

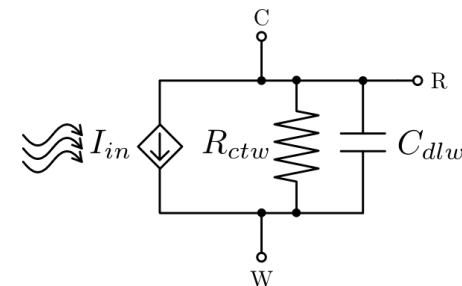
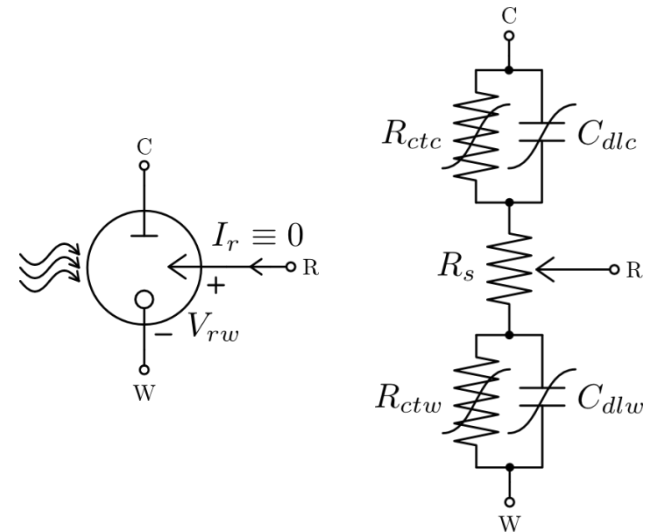
▼ **Classic** circuit interface require multiple OpAmps + resistors + ADC

▲ **Low-power MOS-only** circuit proposal based on mixed electronic and chemical domain potentiostatic $\Delta\Sigma$ modulator



Sensor Modeling

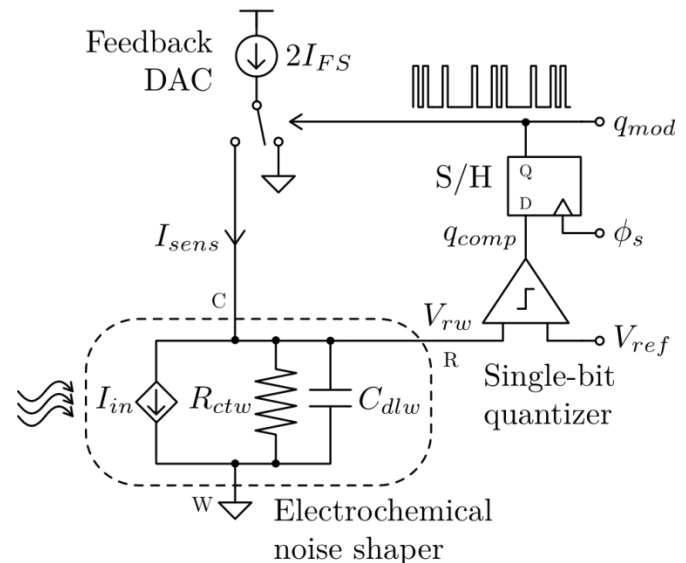
- ▶ Reuse of **sensor dynamics** for circuit design needs accurate device modeling
- ▶ **R**eference, **W**orking and **C**ounter planar microelectrodes
- ▶ Non-linear electrical impedance model under **potentiostatic** operation:
 - R_s = electrolyte solution resistance
 - R_{ctx} = charge-transfer resistance
 - C_{dlx} = double-layer capacitance
- ▲ **Solution resistance** smaller than electrode-solution counterparts ($10^2 k\Omega$)
- ▲ Similar impedance results with internal (micro) or external (macro) **counter microelectrodes**
- ▲ Equivalent linear **dynamic model**



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$\Delta\Sigma$ Modulator Architecture

- ▶ Behavior similar to **low-pass first-order single-bit CT $\Delta\Sigma$ A/D modulator**
- ▶ Error current is converted into voltage and shaped in frequency by the **electrochemical sensor** itself
- ▶ Quantization, S/H and DAC feedback in **electronic domain**
- ▲ **Amperometric** read-out through $\Delta\Sigma$ modulation of output bit stream q_{mod} by chemical input I_{in}
- ▲ Overall negative feedback ensures **potentiostatic** operation by keeping V_{rw} biased close to V_{ref} potential
- ▲ High oversampling ratios (**OSR > 100**) can be easily obtained with kHz-range clock frequencies f_s



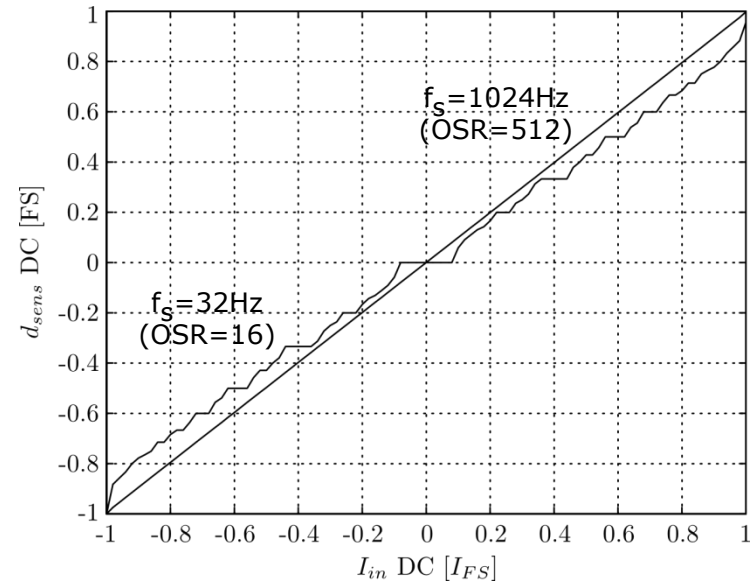
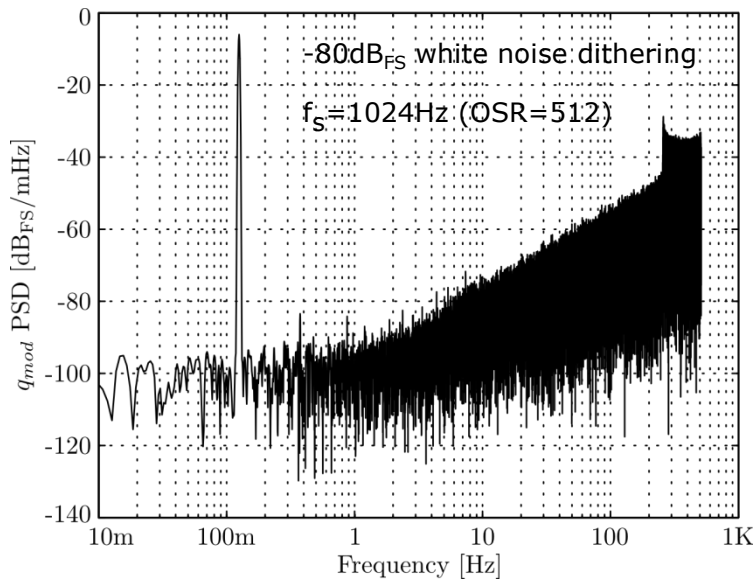
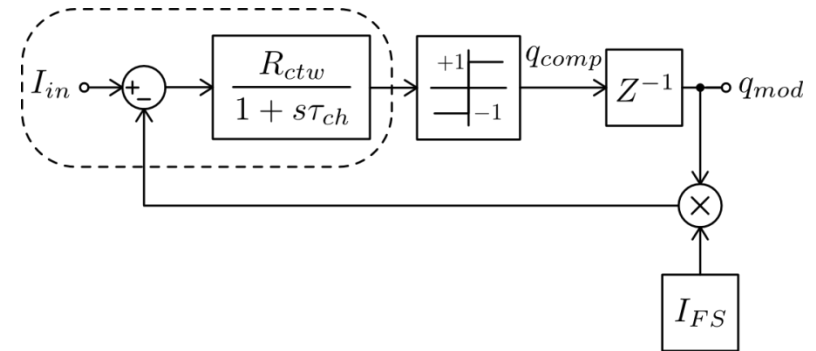
Class-A **full scale:**
$$I_{FS} = \frac{V_{ref}}{R_{ctw}}$$

Electrochemical **time constant:**

$$\tau_{ch} = R_{ctw}C_{dlw} \sim 10^{-1} s$$

$\Delta\Sigma$ Modulator Optimization

- ▼ Typical **tonal components** of first-order $\Delta\Sigma$ modulation are attenuated through **thermal noise dithering** at DAC
- ▼ Fractal **staircase** DC transfer function due to DT losses of CT electrochemical integrator is improved by **increasing OSR**

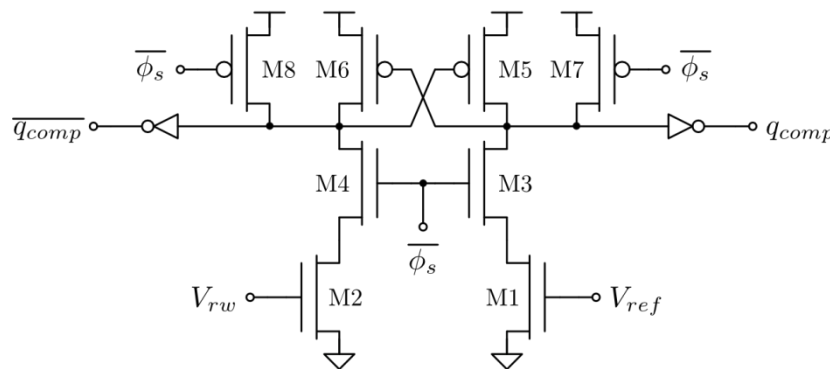


E.g. $\Delta\Sigma$ behavioral simulation for $R_{ctw}=500k\Omega$, $\tau_{ch}=0.16s$, $V_{ref}=1V$ and $I_{FS}=2\mu A$

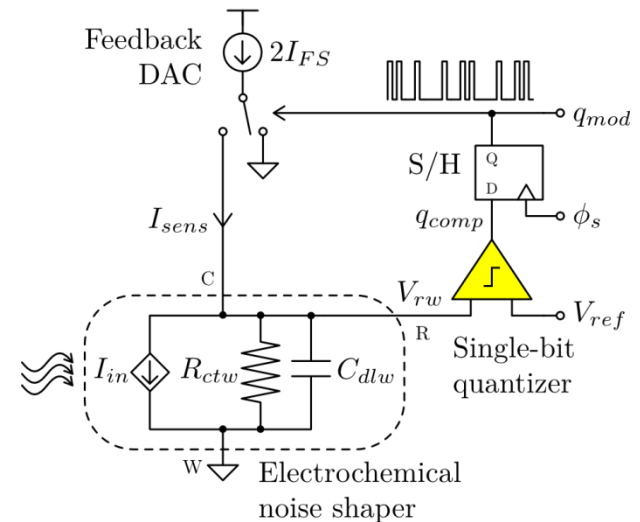
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Low-Power MOS-Only Circuits

- ▲ Two **analog blocks** only
- ▶ **Latched comparator** for 1-bit quantization

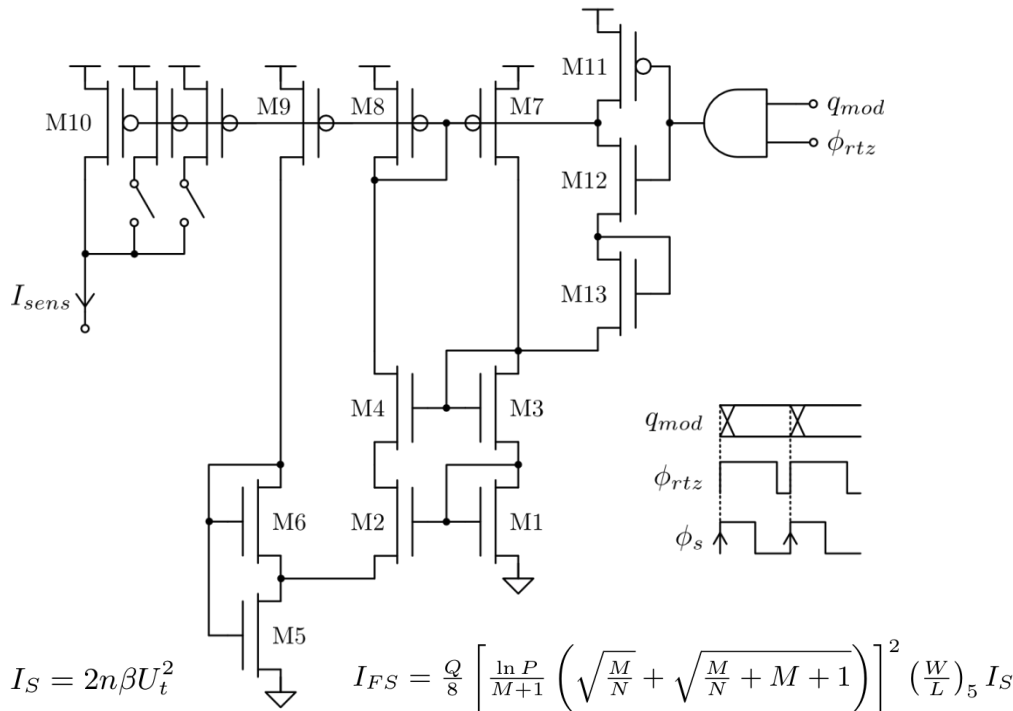


- **Technology mismatching** does not cause distortion but DC offset at V_{rw}
- If V_{ref} is chosen higher than redox potential, electrochemical signals can tolerate comparator **offsets** as large as $\pm 10\text{mV}$



Low-Power MOS-Only Circuits

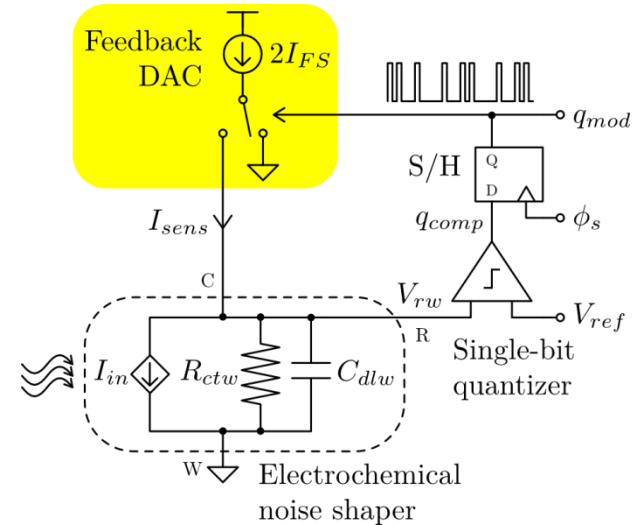
- ▲ Two **analog blocks** only
- ▶ **Latched comparator** for 1-bit quantization
- ▶ **Compact reference generator** for current DAC



$$I_S = 2n\beta U_t^2$$

$$I_{FS} = \frac{Q}{8} \left[\frac{\ln P}{M+1} \left(\sqrt{\frac{M}{N}} + \sqrt{\frac{M}{N} + M + 1} \right) \right]^2 \left(\frac{W}{L} \right)_5 I_S$$

$$Q = \frac{(W/L)_{10}}{(W/L)_8} \quad M = \frac{(W/L)_9}{(W/L)_8} \quad N = \frac{(W/L)_6}{(W/L)_5} \quad P = \frac{(W/L)_2 (W/L)_7}{(W/L)_1 (W/L)_8}$$

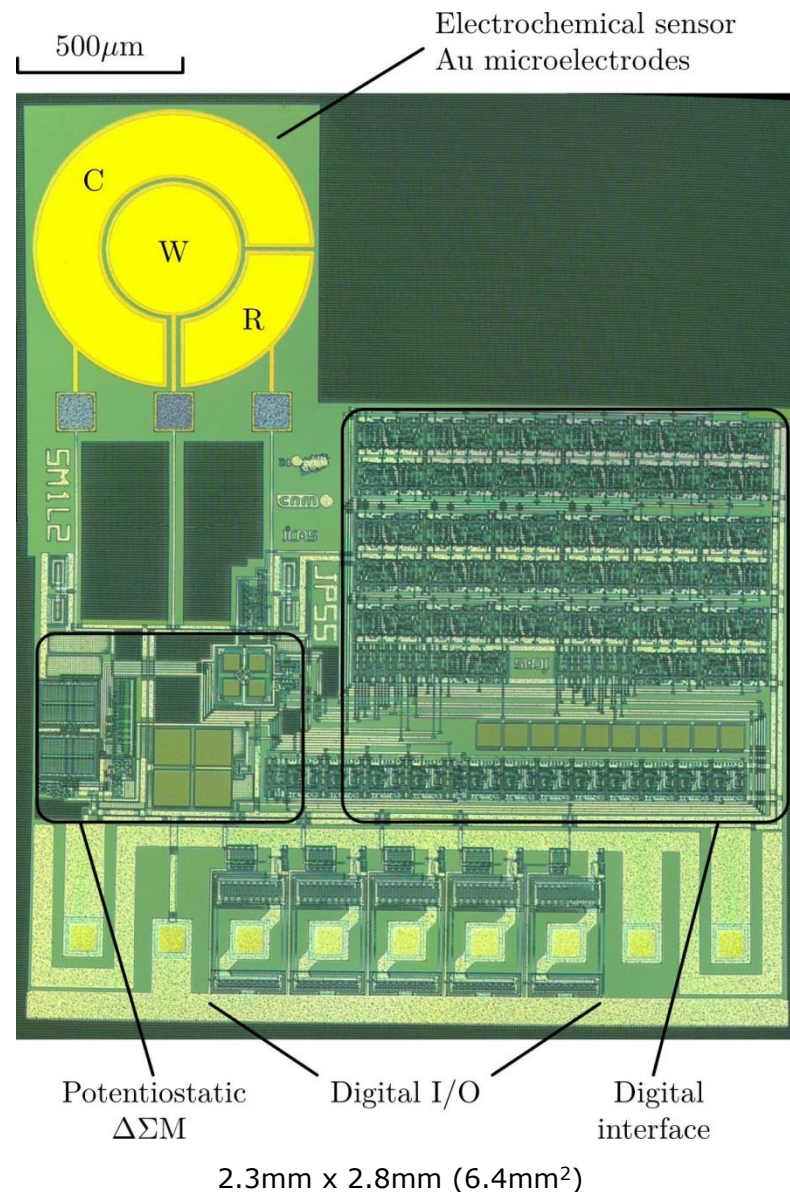


- **Circuit core** based on previous work from these authors [6]
- **Programmable full scale** for different integrated sensor designs
- **Power on/off** instead of current steering operation to reset all MOSFETs and reduce **flicker noise**
- **RTZ** signaling in order to avoid typical waveform asymmetries issues of CT $\Delta\Sigma$ M

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Monolithic CMOS Integration

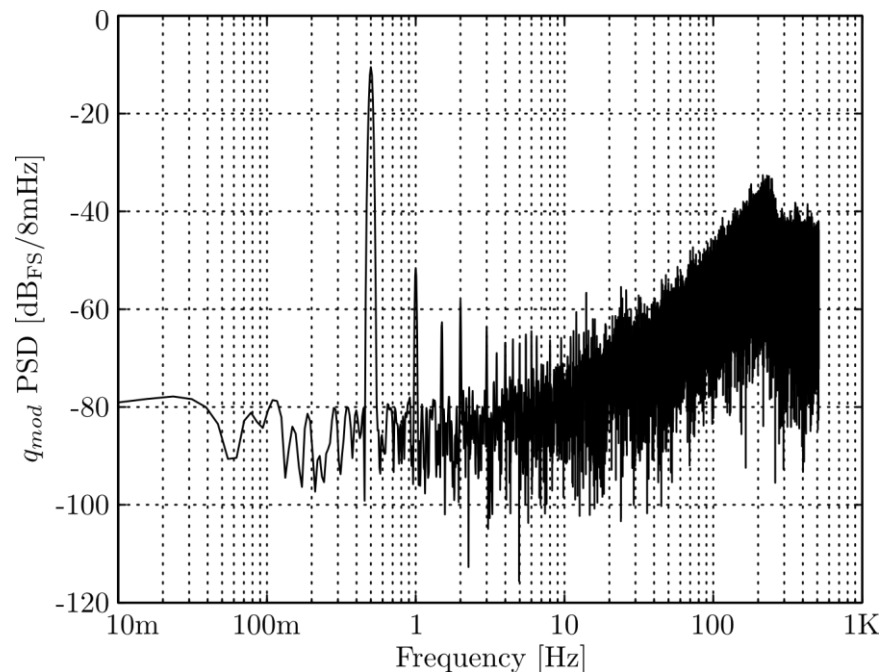
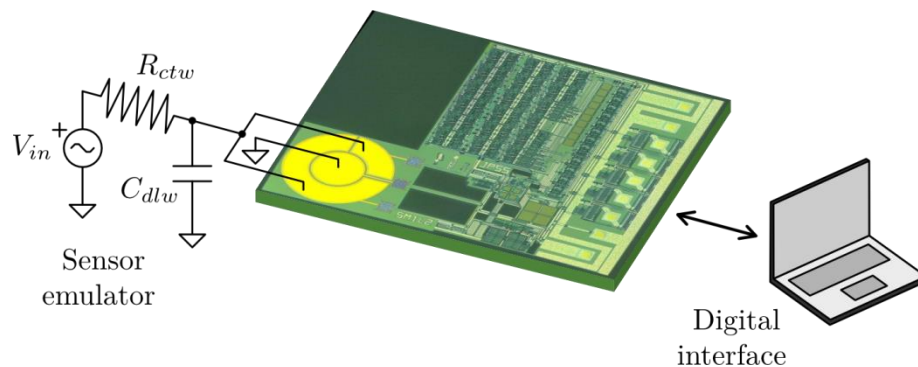
- ▶ Inexpensive 2.5 μm 1M CMOS technology (**CNM25**)
- ▶ In-house **sensor post-processing** at wafer level consisting on sputtering of Ti(15nm)+Au(150nm) thin films and lithographic patterning by lift-off
- ▶ **Sensor** layout design: $D_{\text{in}}=390\mu\text{m}$, $D_{\text{out}}=830\mu\text{m}$ and $S=30\mu\text{m}$
- ▶ **Sensor** electrical model: $R_{\text{ctw}}=500\text{k}\Omega$ and $\tau_{\text{ch}}=0.16\text{s}$
- ▶ **$\Delta\Sigma$** design parameters: $V_{\text{ref}}=1\text{V}$, $I_{\text{FS}}=2\mu\text{A}$ and $f_s=1024\text{Hz}$ (OSR=512)
- ▲ **Low area** overhead of proposed $\Delta\Sigma$
- ▲ **Digital only interface** for low-pass filtering + V_{ref} and I_{FS} programming



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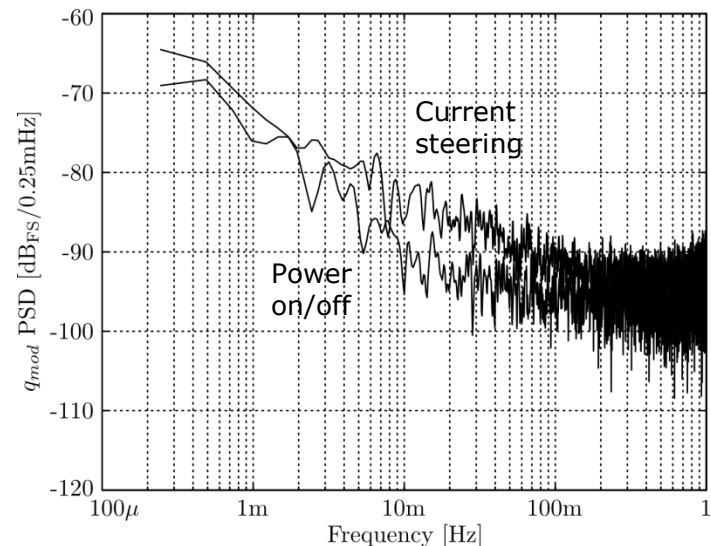
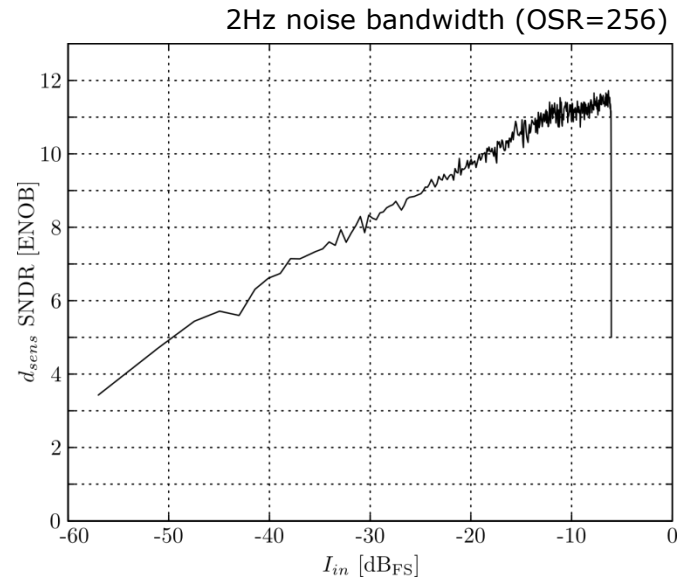
Electrical Tests

- ▶ **Sensor emulation** with external network ($R_{ctw}=510k\Omega$, $C_{dlw}=330nF$) and SRS DS360 generator in equivalent Thévenin configuration
- ▲ Although dithering noise at DAC should be increased, PSD returns good **robustness** against tones



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- ▲ Quasi-static response shows high enough **SNDR** to not limit electrochemical sensor resolution
- ▲ **Statistical analysis** on 9 samples returns DR deviations below $\pm 0.5\text{bit}$
- ▲ Experimental comparison between **power-on/off** and current steering DAC operation points to 3dB flicker noise reduction

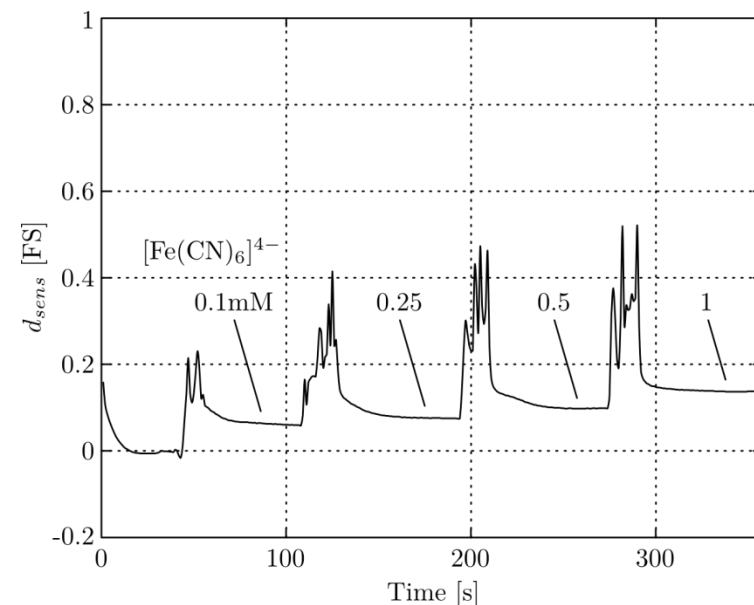
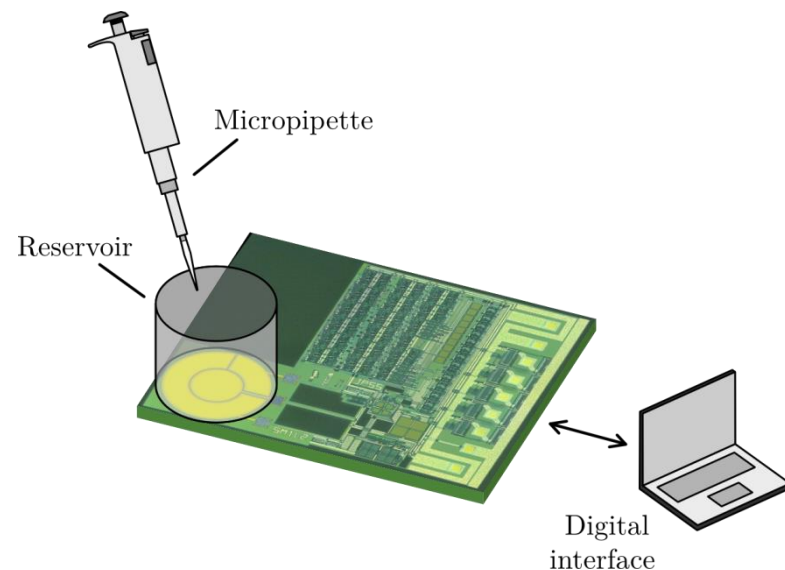


Electrochemical Tests

- ▶ **Standard experiment** based on Ferrocyanide ion oxidation into Ferricyanide



- ▶ **10 μL reservoir** with Ferrocyanide dissolved in Phosphate buffer solution (PBS) at pH=7
- ▶ **Ion concentration** swept from 0.1mM to 1mM and **potentiostatic** $V_{\text{ref}}=0.7\text{V}$
- ▶ Electrochemical **time constant** as expected



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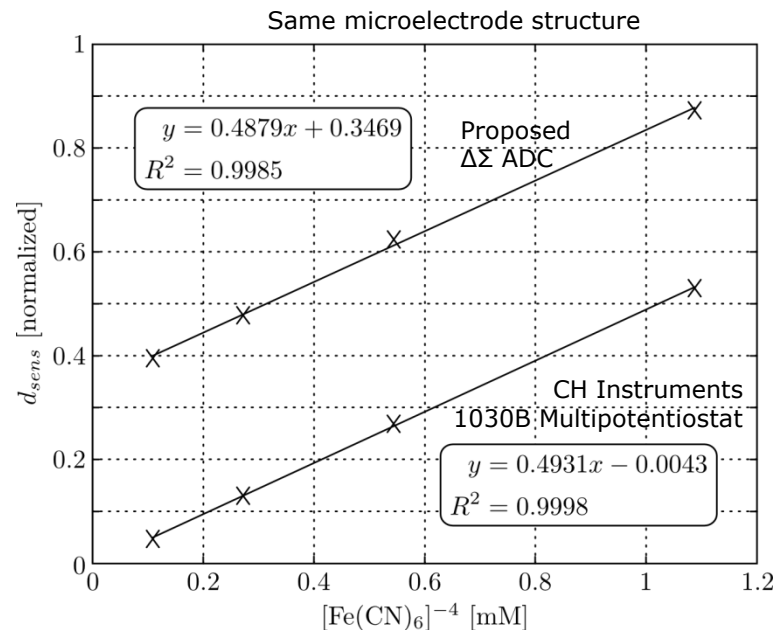
- ▲ Electrochemical **time constant** as expected

- ▲ Remarkable **linearity** below 1mM

- ▲ Comparable to lab **desktop equipment**

- ▲ Good **performance** for sensing applications

- ▲ Very **low-power** operation compared to sensor consumption itself
(can improve with low-voltage CMOS tech)



Parameter	Value	Units
Full scale range	2 to 32	μA
Potential range	0 to 5	V
Sampling frequency	1	kHz
Oversampling ratio	≥ 256	
Electrical dynamic range	> 10	ENOB
Residual standard deviation ($n=6$)	< 15	%
Coefficient of determination (R^2)	0.9985	
Supply voltage	5	V
Power consumption at $2\mu\text{A}_{\text{FS}}$	25	μW
Die size	2.3×2.8	mm^2

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Conclusions

- ▶ **$\Delta\Sigma$ ADC** architecture for potentiostatic biasing and amperometric reading of integrated **electrochemical sensors**
- ▲ Mixed **electro-chemical CT $\Delta\Sigma$ modulator** exploits dynamic behavior of sensors for analog minimalist implementation
- ▼ Accurate sensor **modeling** is needed
- ▲ **Low-power MOS-only** circuits for electronic part of $\Delta\Sigma$ ADC
- ▲ **25 μ W** complete smart sensor in **low-cost** 1M CMOS technology
- ▲ Electrical dynamic range exceeding **10bit** and electrochemical linearity close to **$R^2=0.999$** and **RSD<15%**
- ▲ Comparable in **performance** to commercial desktop equipment

Thanks for your attention!